

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.: 10/621,863
Applicant: Tingkai Li *et al.*
Filed: July 16, 2003
Group #: 2823
Examiner: Hsien Ming Lee

Confirmation Number: 1755

RECEIVED
CENTRAL FAX CENTER

SEP 02 2004

Docket No: SLA.0709
Customer No: 27518
For: MOCVD OF TiO₂ THIN FILM FOR USE AS FeRAM H₂ PASSIVATION
LAYER

MS AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

RESPONSE TO OFFICE ACTION UNDER 37 C.F.R. § 1.111
Introductory Comments

In response to the Office Action dated June 30, 2004, please amend the above-identified Application as follows:

Amendment to the Specification begins on page 2 of this paper.

Amendment to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Amendment to the Drawings None

Remarks/Arguments begin on page 9 of this paper.

An Appendix is not included.